

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of :

Ji-Soo KIM et al. :

Serial No. [NEW] :

Filed: January 30, 2004 :

For: METHOD OF AND APPARATUS FOR MANUFACTURING A
SEMICONDUCTOR DEVICE USING A POLYSILICON HARD MASK

PRELIMINARY AMENDMENT

U.S. Patent and Trademark Office
2011 South Clark Place
Customer Window, Mail Stop Patent Application
Crystal Plaza Two, Lobby, Room 1B03
Arlington, VA 22202

Sir:

Preliminary to the examination of the above-identified application, please enter
the following amendments and consider the following remarks:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins
on page 3 of this paper.

Remarks/Arguments begin on page 5 of this paper.